## Institute of Advanced Energy Device list

as of November, 2023

No		Name of Device/System	Brief Description	Key Person
1.1		High-temperature plasma experimental device of the helical-axis heliotron type	A leading experimental machine to study the nuclear fusion plasma confinement in the helical-axis heliotron magnetic field configuration:  Major radius of the main vacuum chamber: 1.2 m Minor radius of helical coil winding: 0.22 m Average plasma minor radius: 0.15-0.2 m  Helical coil winding: pole number: 1, toroidal pitch number: 4  Nominal magnetic field strength: 1.5 T.	Kazunobu NAGASAKI
1.2		Electron Cyclotron Heating (ECH) System	Plasma production and electron heating system based on electron cyclotron resonance, One unit of Gyrotron oscillator: 70GHz, 500kW, 0.2s Polalization Control System Wave-Llaunching System	Kazunobu NAGASAKI
1.3	Heliotron J	Neutral Beam Injection (NBI) Heating System	This device injects high-energy hydrogen neutral beam into hot plasmas and heats the plasma. Acceleration voltage: 30 kV  Acceleration current: 50 A  Minimum beam divergence angle: 1.2 degree  Proton ratio: 85% Pulse width: 0.2 s Neutralization efficiency: 60%	Shinji Kobayashi
1.4		ICRF Heating System	Heating system for ions and electrons in a plasma through waves in ion cyclotron range of frequencies (ICRF) are generated and injected into plasma for plasma heating. Range of Frequency: 17.8 MHz - 53.4 MHz, Max. Power: 3MW, Pulse Width: 0.2 s	Kazunobu NAGASAKI
1.5		Diagnostic System for Heliotron J	A Family of Diagnostic Devices for Heliotron J Plasma Experiments including Thomson Scattering Systems, A Charge Exchange Recombination, Spectroscopy System, ECE Radiometers, Spectrometers (Visible, VUV), Soft X-ray Detector Arrays, Hard X-ray Detectors, Microwave reflectometer, A Charge-Exchange Neutral Particle Energy Analyzer, A Beam Emission Spectrometer System, Interferometers, Magnetic Probes, Langmuir Probes, A High Speed TV camera System, A Residual Gas Analyzer, A Data Acquisition System, etc.	Takashi MINAMI
2	Two NMR machines (Bruker Avance III and DRX600, 600 MHz)		Analysis of chemical structure, three-dimensional structure, dynamics and interaction in solution as to biomass and biomolecules  Observable nuclei: 1H, 2H, 13C and 15N  Probe: TCI, highly sensitive cryogenic probe for 1H and 13C nuclei	Masato KATAHIRA
3	Electrochemical Analyzer (BAS, BAS100B/W)		Electrochemical analysis/measurement for liquid samples Range of sensitivity: 100 nA/V-100 mA/V AC Impedance Module、Rotating Disk Electrode	Takashi MORII
4	Electron Linac for Free Electron Laser (Nissin-Denki, NKM- 150K,NKM-250K)★		Electron accelerator to generate MIR wavelegth region Free Electron Laser. Electron beams can also be available to irradiate samples.  High pulse power Radio Frequency amplifire  Thermionic cathode RF gun (AET、GP-500)  Electron beam:Maximum acceleration energy of 40MeV, Maximun beam power of 60W in average. MIR-Laser:3.4-25 $\mu$ m, Maximum macro-pulse energy 80mJ@8 $\mu$ m	Hideaki OHGAKI
5	Discharge-type Fusion Neutron Generator		Nuclear fusion device for neutron irradiation  Neutron energy: 2.45MeV (monoenergy) Neutron yield: 10 <sup>8</sup> n/sec (CW)  Distance between target and generator centor: >20cm  Continuous irradiation duration: < 8hrs/day	Juro YAGI
6	Low energy	ion mill	Specimen preparation for TEM observation 100-2,000eV, lon current more than $50\mu$ A; 2.5 $\mu$ m/h@500eV, $28\mu$ m/h@2,000eV	Kiyohiro YABUUCHI
7	Electroporator		Gene transfer for cell Output Waveform: Exponential decay or Square wave Output Voltage: 10-500V (Low Voltage Circuit, CE module) 200-3000V (High Voltage Circuit, PC module)	Takashi MORII
8	Incubator sh	naker (Innova 4230)	Incubator for the shaking culture of microorganism Swing speed : 25-400rpm, Temperature range : 4-80°C	Takashi MORII
9	Ultrasonic d	isintegrator I model XL2020)	For ultrasonic disintegration of cell structure  Maximum Output: 550W, Frequency: 19.8kHz	Takashi MORII
10		eze Dryer (FZ-12SF)	For vacuum freeze drying for frozen samples 12 Port Drying Chamber	Takashi MORII
11	Photolumine	escence Measurement system	Measurement of PL from functional materials Laser 325nm (10mW), 442nm(50mW), Detector : electric cooled CCD	Hideaki OHGAKI
12	Transmission electron microscope (JEM-20X JEX-20)		Microstructural observation  Maxium accelerating voltage 200KV;  Resolution 0.25nm (particles) 1.14nm (latticess); Available for high title angle	Kiyohiro YABUUCHI
13	X-ray Micro	ectron Microscope with Energy Dispersive analysis EX-23000BU)	Observation of SEM images Resolution:3.0nm, X-ray analysis from Na to U by Si(Li) X-ray detector	Kazunari MATSUDA

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		Achieves wavelength scanning with sensitivity and high-speed	
14	Fluorescence Spectrophotometer (F-4500)	Wavelength range : 200-730 nm,	Takashi MORII
		Fluorescence anisotropy measurement is available.	
15	Scanning Probe Microscope (Digital Instruments NANOSCOPE IIIa)	Scanning probe microscope which able to measure surface morphology and to probe	Hiroshi SAKAGUCHI
		local characterization	
15		such as force curve and surface potential.	
		STM and AFM measurements are available in the environment in air and liquid.	
	Transmission electron microscope (JEM-2200FS)	Microstructural observation	Kiyohiro YABUUCHI
16		Maxium accelerating voltage 200KV;	
		Resolution 0.23nm (particles) 0.1 nm (latticess); Availiable for high resolution	
	Scanning electron microscope availiable in coarse vacuum condition (JSM-5600LV)	Observation of the reflected electron image in coarse vacuum condition	Kiyohiro YABUUCHI
		Resolution: 3.5nm in high vacuum condition (30kV, WD6mm, secondary electron image)	
17		5.0nm in low vacuum condition (30kV, WD8mm, reflected electron image) Vacuum:	
		10-270Pa	
	Field Emission Scanning Electron Microscopy (FE-SEM)( ULTRA55)	Observation of material surface and fracture surface, the corresponding chemical	Kiyohiro YABUUCHI
		analysis, crystal orientation	
18		and measuring residual strain	
		Accelerated voltage 30KV;	
		Hypersensitivity; Secondary electron detector; SDD type EDX; Equipping with EBSP	
	Streak Camera(C6138s)	An instrument for measuring the variation in a pulse of light's intensity with time	Hideaki OHGAKI
19		Resolution: 200 fs	
		Spectral range:400-850nm	
	Ultracentrifuge with temperature control (XL-80K)	Adaptable solutions for separation, pelleting, harvesting & elutriation.	Takashi MORII
20		Max Speed : 80,000rpm,	
20		2 rotors were available (type 70.1, type 50.2)	
		Adaptable solutions for separation, pelleting, harvesting & elutriation.	
21	igh Speed Centrifuge with temperature control (Avanti	Max Speed : 25,000rpm,	Takashi MORII
19 20 21	HP-25)	3 rotors were available (JLA-10, JA-20, JA-21)	
		Cold storage equipment (4°C) Temperature range 0-7°C	
22	chromatochamber (ALS-720F)	Strage 1000 L	Takashi MORII
	Clean bench (clean Air Equipment) (S-1300PRV)	Ventilated laboratory workspace for safely working with materials contaminated with (or	Takashi MORII
		potentially contaminated with) pathogens requiring a defined biosafety level.	
23		Single-Faced Type P-series. Air circulation type	
0		The air in working space by treatment with HEPA filter will rotate. HEPA filter last for a	
		long time. W1300xD750xH1810mm	
		Cold storage equipment (-80°C)	
24	Freezers (ULT-1386-3)	Temperature range -65~-86°C, Strage 379 L	Takashi MORII
25	800 MHz LC-NMR/MS	800 MHz NMR conbined with liquid chromatography and mass spectroscopy, Four channel	Masato KATAHIRA